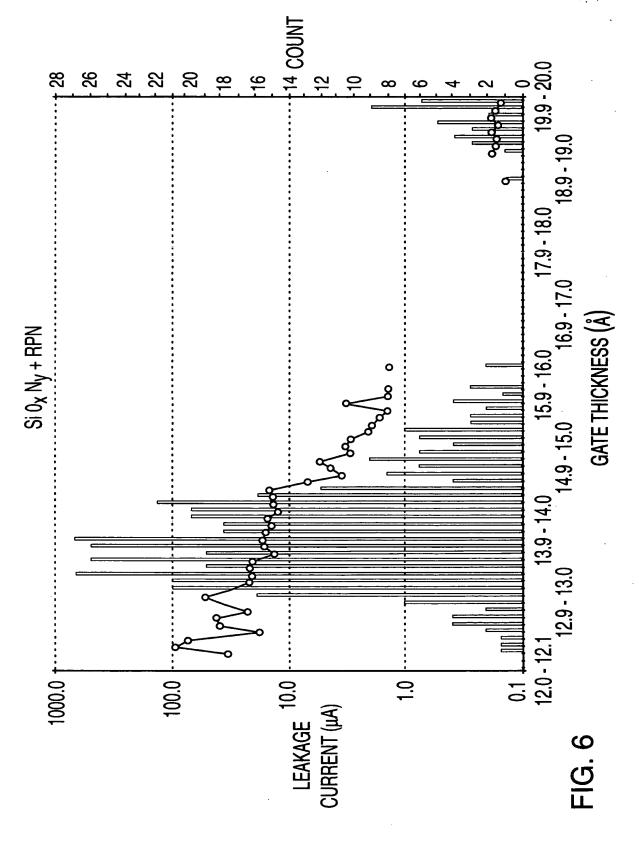


GATE THICKNESS (Å)

17.9 - 18.0

15.9 - 16.0 14.9 - 15.0 16.9 - 17.0

FIG. 5



DOBDOSEL DIFOSOL

UNIFORMITY OF GATE FILM

	MEAN THICKNESS (nm)	<u> </u>
RPN of Si O ₂ (Dry)	1.74	0.287
RPN of Si O ₂ (Wet)	1.68	0.115
RTNO	1.70	0.0293
RTNO +RPN@ 550°C	1.74	0.0246
RTNO +RPN@ 750°C	1.73	0.0296

FIG. 7

